

ABSTRACT

METHOD FOR MANUFACTURING GLASS SUBSTRATE FOR
INFORMATION RECORDING MEDIUM

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In the method for manufacturing a substrate for an information recording medium, in a state in which a slurry is supplied to a polishing pad (410), the attraction force of the polishing pad (410) on a substrate (1) is not less than 0.50 g/cm^2 and not more than 15 g/cm^2 .

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Fig. 7